

L Number	Hits	Search Text	IP	Time Stamp
1	1	313/587 and borosilicate with alkali	USPAT	2001/11/13 17:41
2	1	313/587 and borosilicate with alkali	USPAT	2001/11/13 17:41
3	2	313/587 and borosilicate same alkali	USPAT	2001/11/13 17:41
4	2	313/587 and borosilicate same alkali	USPAT	2001/11/13 17:41
5	138	liquid adj crystal and borosilicate same alkali	USPAT	2001/11/13 17:41
6	13	liquid adj crystal same borosilicate same alkali	USPAT	2001/11/13 17:41
7	4	"5851939" "5050147" "5194770" "5519867".PH.	USPAT	2001/11/13 07:10
8	4	"5851939" "5050147" "5194770" "5519867".PH. and alkali	USPAT	2001/11/13 07:10
9	2	313/587 and borosilicate same alkali and liquid adj crystal	USPAT	2001/11/13 07:10
10	3	"5851939" "5050147" "5194770" "5519867".PH. and distillation crack\$3	USPAT	2001/11/13 07:10
-	3	313/587 and thickness r thick with Mn	USPAT	2001/11/13 17:41
-	48	313/587 and thickness r thick with angstr\$	USPAT	2001/11/13 17:41
-	146	313/587 and thickness r thick with dielectric	USPAT	2001/11/13 17:41
-	39	313/587 and thickness r thick with dielectric same oxide	USPAT	2001/11/13 17:41
-	15	313/587 and thickness r thick with dielectric same oxide same electrode	USPAT	2001/11/13 17:41
-	3	313/587 and cvd with dielectric or oxide) same electrode	USPAT	2001/11/13 17:41
-	4	313/587 and cvd same dielectric or oxide) same electrode	USPAT	2001/11/13 17:41
-	19	PDP and electrode with oxidiz\$	USPAT	2001/11/13 17:41
-	0	PDP and electrode with oxidiz\$ same anodic	USPAT	2001/11/13 17:41
-	5	PDP and electrode with oxidat\$ same anodic	USPAT	2001/11/13 17:41
-	6	PDP and electrode with oxidiz\$ same dielectric	USPAT	2001/11/13 17:41
-	2	"5791960" and (anodic\$ or anodic)	USPAT	2001/11/13 17:41
-	0	PDP and anodizing same insulator same electrode	USPAT	2001/11/13 17:41
-	0	PDP and anodizing same insulator	USPAT	2001/11/13 17:41
-	1	PDP and anodi\$ same insulator	USPAT	2001/11/13 17:41
-	1	PDP and anodi\$ same insulator	USPAT	2001/11/13 17:41
-	1	PDP and anodi\$ same insulator and "4-4"	USPAT	2001/11/13 17:41
-	22	313/587 and cvd	USPAT	2001/11/13 17:41
-	4	313/587 and plasma adj spray\$	USPAT	2001/11/13 17:41
-	1	313/587 and plasma adj spray\$ same partition	USPAT	2001/11/13 17:41
-	0	"57105955"	USPAT	2001/11/13 17:41
-	1	"57105955"	DEPVENT	2001/11/13 17:41
-	2	313/587 and aluminum with plasma adj spray	DEPVENT	2001/11/13 17:41
-	1	313/587 and plasma with spray	DEPVENT	2001/11/13 17:41

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-	0	313/582 and plasma some spray	DEPONENT	11/11/84
-	14	313/582 and plasma with spray	USIAT	11/11/84
-	13	444/14 and plasma with spray	USIAT	11/11/84
-	1	07105855.ph.	DEPONENT	11/11/84
-	99	313/586 and CVD in vacuum with Dep sition.	USIAT	11/11/84
-	106	313/586 and CVD in sputterco. of vapor ad. dep sition. in vacuum with dep sition. same electrode	USIAT	11/11/84
-	1	"5.115 ".PH.	USIAT	11/11/84